Wh

Notice of Allowability	Application No.	Applicant(s)
	09/846,707	KULA ET AL.
	Examiner	Art Unit
	Brian E. Miller	2652
The MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIP of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ag or other appropriate communication GHTS. This application is subject and MPEP 1308.	oplication. If not included on will be mailed in due course. THIS
1. X This communication is responsive to Amendments filed 11/4/04 & 12/16/04.		
2. 🔀 The allowed claim(s) is/are <u>2-11,13-16,19 and 20 (renumb</u>	ered as 2-3, 1, 4-7, 10, 8-9, 12-13,	<u>11, 14-16)</u> .
3. $igotimes$ The drawings filed on $4/30/01$ & 11/4/04 are accepted by the	ne Examiner.	
4. Acknowledgment is made of a claim for foreign priority una) All b) Some* c) None of the:  1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	been received. been received in Application No cuments have been received in this of this communication to file a reply IENT of this application.	s national stage application from the
<ol> <li>A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give</li> </ol>		
6. ☐ CORRECTED DRAWINGS (as "replacement sheets") must (a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No./Mail Date  (b) ☐ including changes required by the attached Examiner's Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in to T. ☐ DEPOSIT OF and/or INFORMATION about the deport attached Examiner's comment regarding REQUIREMENT	con's Patent Drawing Review (PTC).  s Amendment / Comment or in the  .84(c)) should be written on the draw he header according to 37 CFR 1.121 sit of BIOLOGICAL MATERIAL	Office action of ings in the front (not the back) of (d). must be submitted. Note the
Attachment(s)  1. ☐ Notice of References Cited (PTO-892)  2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)  3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date  4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Summar Paper No./Mail Da 7. ⊠ Examiner's Amend	ate Iment/Comment nent of Reasons for Allowance

Claims 2-11, 13-16, 19-20 are now pending.

## Examiner's Amendment/Comments

Page 2

1. The Amendments filed 11/4/04 and 12/16/04, in combination, are considered to incorporate all the claim changes necessary to place the application in condition for allowance. It is noted though that the claim status identifier for claim 11 must be changed to read "CURRENTLY AMENDED", which will be done by the Examiner.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Brian E. Miller whose telephone number is (571) 272-7578. The examiner can normally be reached on M-TH 7:15am-4:45pm (and every other friday).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Hoa T. Nguyen can be reached on (571) 272-7579. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Brian E. Miller

Primary Examiner

Art Unit 2652

Dec 16 04 01:50p

an upper layer disposed adjacent the underlayer and the pinning layer, the upper layer comprising at least one material selected from the group consisting of NiFe and CoFe for increasing a GMR ratio associated with the SV sensor;

wherein the sensor provides an increase of  $\Delta R/R$  of at least 5% when compared to an otherwise identical sensor not having the upper layer;

wherein the upper layer includes both NiFe and CoFe.

- 10. (CURRENTLY AMENDED) The spin valve sensor as recited in claim [[1]] 4, wherein the underlayer comprises NiFeX where X is not Cr.
- CURRENTLY AMENDED

  (PREVIOUSLY PRESENTED) The spin valve sensor as recited in claim [[1]] 4, wherein the upper layer is non-magnetic.
- 12. CANCEL
- 13. (CURRENTLY AMENDED) The method as recited in claim [[12]] 15, wherein the upper layer has a thickness of at least 4 A.
- 14. (PREVIOUSLY PRESENTED) The method as recited in claim 13, wherein the upper layer has a thickness of no more than 20 A.
- 15.. (PREVIOUSLY PRESENTED) A method of fabricating a spin valve (SV) sensor comprising:

depositing an underlayer comprising NiFeX, where X is not Cr;

depositing an upper layer adjacent the underlayer, the upper layer comprising at least one material selected from the group consisting of NiFe and CoFe for increasing a GMR ratio associated with the SV sensor;

depositing a pinning layer towards the upper layer;